INFORMATION DISCLOSURE STATEMENT (IDS) BY APPLICANT

(FORM PTO-1449 Modified)

Application Number	10/560,804
Filing Date (YYYY-MM-DD)	2005-12-15
First Named Inventor	Jawad HAIDAR
Art Unit	1734
Examiner Name	ZHU, Weiping
Attorney Docket Number	CU-4560

U.S. PATENTS

EXAMINER INITIAL	U.S. PATENT NUMBER	ISSUE DATE (YYYY-MM-DD)	PATENTEE	CLASS	SUB- CLASS	FILING DATE (YYYY-MM-DD)
	4,877,445 (Corresponds to JP64-15334	1989-10-31	Okudaira et al.			
	4,437,888	1984-03-20	Jecker			

U.S. PATENT APPLICATION PUBLICATIONS

EXAMINER	U.S. PATENT APPLICATION	PUBL, DATE			SUB-	FILING DATE
INITIAL	PUBLICATION NUMBER	(YYYY-MM-DD)	PATENTEE	CLASS	CLASS	(YYYY-MM-DD)

FOREIGN PATENT DOCUMENTS

			7 [4] 4 4 1 4 1	WITH PACE	P. 161 P. 1. P.	
EXAMINER INITIAL	FOREIGN PATENT DOCUMENT NUMBER	COUNTRY CODE	KIND CODE	PUBL. DATE (YYYY-MM-DD)	NAME OF PATENTEE OR APPLICANT OF THE CITED DOCUMENT	IBANSLATION YES NO
	754 869	GB	Α	1956-08-15	Kaiser Aluminium Chem Corp	
	2 158 102	GB	Α	1985-11-06	Vale Do Rio Doce Co	
	1 516 257 (Corresponds to JP52-32988)	GB	Α	1978-06-28	Stauffer Chemical Company	
	52-32988 (Corresponds to GB1516257)	JP		1977-03-12	Stauffer Chemical Company	
	64-15334 (Corresponds to US4,877,445)	JP	Α	1989-01-19	Okudaira et al.	
	92/14851	WO	A1	1992-09-03	The University of Melbourne	
	2005/002766	wo	A1	2005-01-13	Commonwealth Scientific and Industrial Research Organisation	
	38454	UA	Α	2001-05-15	Zavadovski, Vera M. et al.	

NON-PATENT LITERATURE DOCUMENTS

	9 9 70 8 1 2 3 3 0 0000 K 5 0000 K 70 5 70 70 70 70 70 70 70 70 70 70 70 70 70							
	EXAMINER	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial TRANSLATION	ĺ					
-	INITIAL	symposium catalog, etc.) date, page(s), volume-issue number(s), publisher, city and/or country where published. YES NO						
	EXAMINER	DATE CONSIDERED						
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EXAMINER: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.